Amendments to the Specification:

At page 1, line 3 please add the following heading and subheading as shown below:

BACKGROUND OF THE INVENTION

1. Field of the Invention

At page 1, line 6, please add the following subheading as shown below:

2. Description of the Related Art

At page 3, line 11, please add the following heading as shown below:

SUMMARY OF THE INVENTION

At page 3, line 16, please add the following heading as shown below:

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENT(S)

At page 3, line 17, please amend the paragraph as shown below:

This and other objects are achieved by the present invention, relating to a process for preparing halogen-containing silanes of the general formula (I):

 $R_a H_b SiX_c$ (I)

where

Atty Dkt No. WAS0662PUSA

S/N: PCT/DE03/01270

R is a substituted or unsubstituted alkyl or aryl radical having from 1 to 10 carbon atoms of which one or more may be replaced by -CO-, -CO₂-, -O-, -S-, -SO-, -SO₂-, -NH- or -NR'-, where R' is a substituted or unsubstituted alkyl radical having from 1 to 20 carbon atoms,

X is fluorine, chlorine or bromine,

a is an integer of 0, 1, 2 or 3,

b is an integer of 0, 1, 2 or 3 and

c is an integer of 1, 2, 3 or 4,

with the proviso that the sum of a + b + c = 4, characterized in that silicon, under the action of microwave energy, is reacted with mixtures of the elements or compounds selected from the group consisting of halogens; [[or]] halogens and organohalogen compounds; [[or]] halogens and hydrogen; [[or]] halogens and hydrogen halides; [[or]] organohalogen compounds and hydrogen compounds and hydrogen halide; [[or]] hydrogen halides; [[or]] fluorosilanes and hydrogen; [[or]] fluorosilanes and hydrogen halide; [[or]] hydrogen-containing chlorosilanes and hydrogen; [[or]] hydrogen-containing chlorosilanes and hydrogen; [[or]] organohalosilanes and hydrogen; [[or]] organohalosilanes and hydrogen halides; [[or]] and hydrocarbons and hydrogen halides.

At page 8, line 11, please amend the paragraph as shown below:

 $0.4 \text{ g of Si} + \text{HCl}_{(g)} \rightarrow \text{HSiCl}_3 + \text{SiCl}_4 + \text{further silanes}$ (isolated yield: 1.62 g = 60% based on Si)